

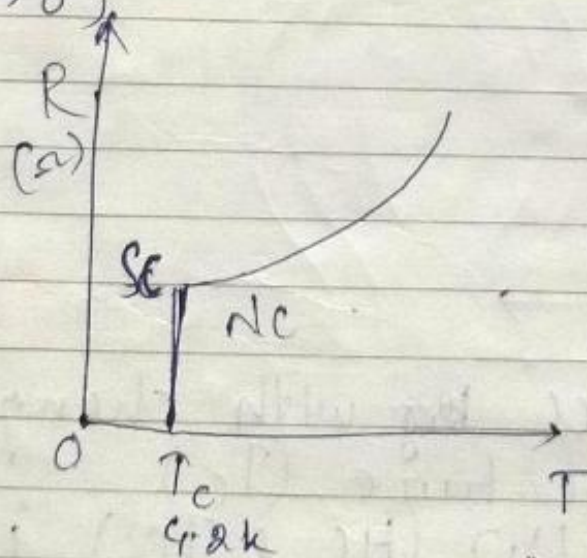
Unit - IV PHYSICAL MATERIAL
AND
OPTO-ELECTRONICS

There are different types of materials which are used for various applications. They are :-

- 1) Superconducting materials
- 2) Magnetic Materials
- 3) Di-electric materials
- 4) Nano-materials
- 5) Semiconducting materials
- 6) Conducting materials

Superconducting Materials

When the resistivity of a conductor decreases and tends to 0, while ^{lowering} its temperature, then this conductor is called superconductor and the phenomenon is called superconductivity ($R \rightarrow 0$).



T_c - critical temperature

NC = Normal Conducting

SC - Superconducting

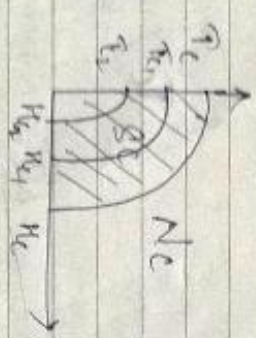
characteristics of superconductor :-
Critical temperature (T_c)
(or)

Transition Temp (T_c)

$T > T_c \rightarrow NC$
 $T < T_c \rightarrow SC$

1) Critical temperature: It is the temperature where the normal conductor elements to superconductor (SC).

2. Critical magnetic field (H_c)
 The magnetic field affect the superconductivity.
 Critical magnetic field is defined as the maximum value of magnetic field with which the material below superconducts and beyond this value it becomes normal conductor.



The H_c changes with changing of critical temperature (T_c)
 The relation b/w (H_c & T_c) is given by

$$H_c = H_0 \left[1 - \left(\frac{T}{T_c} \right)^2 \right]$$

$H_0 \rightarrow$ critical magnetic field at 0K.
 $T \rightarrow$ any temp

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3) Isotopic mass effect:-

The superconductivity depends on the isotopic mass of the substance.
 Mathematically, the critical temp is inversely proportional to the square root even of the isotopic mass.

$$T_c \propto \frac{1}{M^{1/2}} \Rightarrow T_c M^{1/2} = \text{constant}$$

eg $T_{c1}, M_1 \rightarrow T_{c2}, M_2$

$$\left[\frac{T_{c1}}{T_{c2}} \right] = \left[\frac{M_2}{M_1} \right]^{1/2}$$

4) Critical current and current density:-
 Critical current depends on the critical magnetic field and the radius of the material.

$$\text{Mathematically, } I_c = 2\pi r H_c$$

where r = radius of the wire
 H_c = critical magnetic field

Critical current density (J_c)

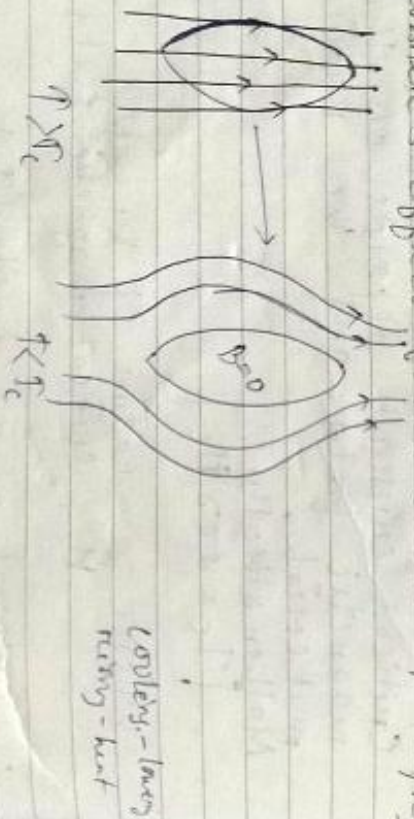
$$J_c = \frac{I_c}{A} = \frac{2\pi r H_c}{\pi r^2} = \frac{2 H_c}{r}$$

$$J_c = \frac{2 H_c}{r}$$

5. Entropy (S) :- Entropy measures the disorderliness of a system. The entropy of a superconducting material is lower than the normal conductor.



6. Meissner's effect (Flux exclusion principle)



When a superconducting substance is cooled under a magnetic field below critical temperature then the magnetic flux is expelled from the specimen as if the magnetic field inside the specimen is 0. (Diamagnetic material)

$$\chi = 0$$

$$\Rightarrow \chi = -\chi_c$$

called as Their effect is, Meissner's effect. \Rightarrow A superconducting material is perfect diamagnetic material.

Q The critical temp for Hg of atomic mass 199.5 amu is 4.195 K ; what will be the critical temp when mass changes to 203.5 amu ?

Given that

$$T_{c1} = 4.195\text{ K}$$

$$M_1 = 199.5\text{ amu}$$

$$M_2 = 203.5\text{ amu}$$

$$\frac{T_{c1}}{T_{c2}} = \left[\frac{M_2}{M_1} \right]^{1/2}$$

$$= \frac{4.195}{T_{c2}} = \left[\frac{203.5}{199.5} \right]^{1/2} = 1.0020$$

$$\frac{4.195}{T_{c2}} = 1.009$$

$$T_{c2} = \frac{4.195}{1.009} = 4.15\text{ K}$$

$$T_{c2} = 4.15\text{ K} \text{ Ans.}$$

Q2 Calculate the critical current density (J_c) for 1 mm diameter wire of

At 4K when T_c is equal to 1.196K

$$H_0 = 7.9 \times 10^3 \text{ A/m}$$

$$T_c = 1.196 \text{ K}, T = 4 \text{ K}$$

$$2x = 1 \text{ mm} = 10^{-3} \text{ m}$$

$$T_c = 2\pi \times H_c$$

$$H_c = H_0 \left[1 - \left(\frac{T}{T_c} \right)^2 \right]$$

$$= 7.9 \times 10^3 \left[1 - \left(\frac{4}{1.196} \right)^2 \right]$$

$$= 7.9 \times 10^3 \left[1 - (0.83)^2 \right]$$

$$\left[1 - 0.69 \right]$$

$$7.9 \times 10^3 \times 0.302$$

$$2.38 \times 10^3 \text{ A/m}$$

$$I_c = \pi (2x) H_c = 7.42 \text{ Amp}$$

$$J = \frac{I_c}{2x} H_c = \frac{2x \times 2.38 \times 10^3}{2}$$

$$= 9.48 \times 10^6 \text{ A/m}^2$$

$$= 9.48 \times 10^6 \text{ A/m}^2$$

Q. Find the critical temp for lead if the critical magnetic field (H_c) is 120 mT at 0K. $9.48 \times 10^6 \text{ A/m}^2$ is the critical temp 4.8K.

$$T_c = 4.8 \text{ K}$$

$$H_c = \frac{1}{20} H_0$$

$$T = ?$$

$$\frac{1}{20} H_0 = H_0 \left[1 - \left(\frac{T}{4.8} \right)^2 \right]$$

$$\frac{1}{20} = 1 - \frac{T^2}{(4.8)^2}$$

$$\frac{1}{20} = 1 - \frac{T^2}{23.04}$$

$$\frac{1}{20} = \frac{23.04 - T^2}{23.04}$$

$$1.152 = 23.04 - T^2$$

$$1.152 - 23.04 = -T^2$$

$$-21.88 = -T^2$$

$$T^2 = 21.88$$

$$T = \sqrt{21.88}$$

$$T = 4.67 \text{ K}$$

Types of superconductors :-
There are 2 types of superconductors :-

(1) Type-I or soft SC

(2) Type-II or hard SC.

Type-I or soft SC

(i) It has low magnetic tolerance power i.e.

when the magnetic field is slightly

Type-II or hard SC

(i) It has high magnetic tolerance power i.e. It

doesn't lose its supercon-

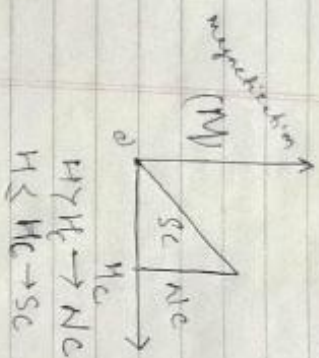
ductivity immediately and

field is slightly

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increase then it loses its superconducting immediately and become normal conductor. Hence is called soft SC.
 Ex: Lead, tin, mercury (Pb), (Sn), (Hg)

(ii) Graphical representation (ii) Graph



$H > H_c \rightarrow NC$
 $H < H_c \rightarrow SC$

(iii)

Type I SC satisfies the Meissner's effect perfectly.

(iv) It has only single critical magnetic field.

It lost its superconducting state for a long time before reaching normal conducting state.
 Ex: Niobium, Vanadium

(ii) Graph



$H < H_{c1} \rightarrow SC$
 $H > H_{c2} \rightarrow NC$

$H_{c1} < H < H_{c2} \rightarrow$ Mixed state

(iii) Type II does not satisfy the Meissner's effect perfectly.

(iv) It has 2 critical magnetic field i.e. H_{c1} & H_{c2}

Applications

Superconducting materials are used for various applications. They are:

(i) SQUIDS: Superconducting Quantum Interface Devices

(ii) Used as CRYTRON These are called as switching devices.

(iii) Used in Magnetic Levitation (Bullet train)

(iv) Used as MRI (Magnetic resonance imaging)

(v) Used in Super computers and electronic devices

(vi) Used in transformers

(vii) Used as super-electromagnets

Magnetic materials:

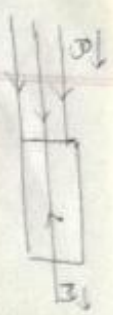
The magnetic behaviour of a material is known the magnetic material.

According to the magnetic behaviour a magnetic material is classified into 3 categories:-

(i) Diamagnetic material

(ii) Para magnetic material

(iii) Ferromagnetic material



Dia

(i) The individual atoms, molecules or ions do not possess any net magnetic moment of their own.

(ii) When these materials are placed in an external magnetic field they acquire a magnetic field in the opposite direction to the applied magnetic field.

(iii) The magnetic susceptibility is negative $\chi < 0$.

(iv) The magnetic susceptibility is independent of temperature.

(v) $\text{Fe}^{2+}, \text{Bi}, \text{Sb}, \text{Cu}, \text{Au}, \text{Hg}, \text{H}_2\text{O}, \text{Alcohol (HCOH)}, \text{air}, \text{Quartz}, \text{H}_2 \text{ gas}.$



Para

(i) The individual atoms, molecules or ions possess a net magnetic moment of their own.

(ii) When they are placed in an external magnetic field they acquire more magnetism along the direction of applied magnetic field.

(iii) The magnetic susceptibility is positive & greater than 1.

(iv) The magnetic susceptibility is dependent on temp. i.e. inversely proportional to T.

(v) $\text{Fe}^{3+}, \text{Al}, \text{Cu}, \text{Mn}, \text{CuSO}_4 \cdot 5\text{H}_2\text{O}, \text{crown glasses}, \text{Ni}, \text{O}_2.$



Ferro

(i) The individual atoms, molecules or ions possess a very strong net magnetic moment of their own.

(ii) When these materials are placed in an external magnetic field they acquire very strong magnetism.

(iii) $\chi > 1$

(iv) $\chi \propto 1/T$

(v) $\text{Fe}, \text{Co}, \text{Fe}, \text{Ni}.$

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Di-electrical Materials

In a di-electrical material electric charge do not flow, like conductor but it gets slightly shifted from their equilibrium position when they are placed in external electric field.

Examples: Different polymers, glass, paper, mica sheet.

Characteristics / properties :-
Dielectric materials are insulators and having high resistivity.

The forbidden gap of the dielectric materials is more than $3 \times 10^6 \text{ eV}$.
All the electron in this material are localised i.e. they are engaged in bonding.

(i) The electrical conductivity is very low.
(ii) The dielectric material have -ve temp co-efficient of resistance.

Classification / types :-
Depending on the electrical dipole moment, dielectric material are classified into.

(1) Polar dielectric material

(2) Non-polar dielectric material
Difference b/w Polar & non-polar D.E.M.

Polar DEN	Non-polar DEN
(i) It has inherent dipole moment	(i) It does not have dipole moment.
(ii) In the presence of electric field, the two +ve charged are separated through a small distance.	(ii) In the presence of electric field they cannot be separated by a small distance.
(iii) It shows the property of polarity	(iii) It does not show polarity.
(iv) These materials are polar compounds	(iv) These materials are non-polar compounds.
(v) The shape of the molecule are asymmetric	(v) The shape of the molecule are not asymmetric.
(vi) Examples: ammonia, NH_3 ,	(vi) Ex: Benzene, ethane

Classification/Type

Depending on the impact of physical parameters like temp, pressure etc, dielectric materials are classified as:-

- (1) Piezo electrical material \rightarrow Piezo electric
- (2) Pyro electric material \rightarrow Pyro electric
- (3) Ferro electric material \rightarrow Ferroelectric

Piezo	Pyro	Ferro
(i) These materials generate electric stress when mechanical stress is applied	These materials generate electricity when they are heated or cooled	These materials show electric polarization even in the absence of electric field

Ex: Crystalline, Quartz, ammonium phosphate	Ex: Quartz	Ex: Lithium Albitate, Barium titanate
(i) These materials are non-symmetrical.	(i) These materials are uni-directional	(i) These materials exhibit dielectric hysteresis.
(ii) These materials are generally used in nature	(ii) These materials are used in temperature sensor.	(ii) These materials show both piezo and pyro properties.
(iii) Generally it is used in microphones	(iii) Generally it is used in memory devices	(iii) These materials are used in memory devices
(iv) These materials are non-polar	(iv) These materials are non-polar	(iv) These materials are non-polar
(v) These materials are generally used in nature	(v) These materials are generally used in nature	(v) These materials are generally used in nature
(vi) These materials are generally used in nature	(vi) These materials are generally used in nature	(vi) These materials are generally used in nature

Application of dielectric materials:-
Dielectric materials are used widely in capacitor, transformer and electrical devices.

Nano-Materials

When the size of the material (atoms) reduces to nano scale (10 nm to 100 nm) then various properties like electrical, physical, mechanical, optical, magnetic etc. have been enhanced.

Surface to volume ratio

$$S:V = \frac{4\pi R^2}{\frac{4\pi R^3}{3}} = \frac{3}{R}$$

Applications:

- (i) Used in various structural applications
- (ii) Electrical circuits
- (iii) Used as fibres, textile,
- (iv) Used as fibres.
- (v) CNT - carbon-nanotube
- (vi) Used as medicines / drugs.
- (vii) Used in computers (hard disks)
- (viii) Used as sensors.
- (ix) Used in paint industrial
- (x) Used as nano composite materials

CNT - Carbon nano tube
 Graphene
 Fullerene

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Opto-electronics

LASER - Light Amplification by Stimulated Emission of Radiation

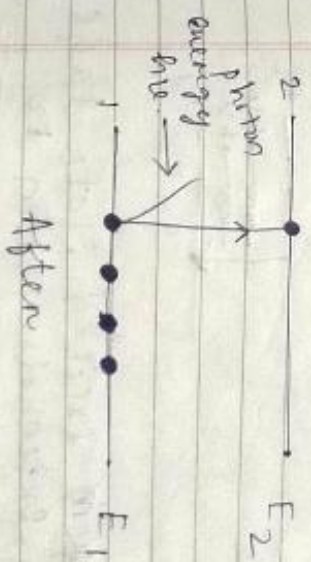
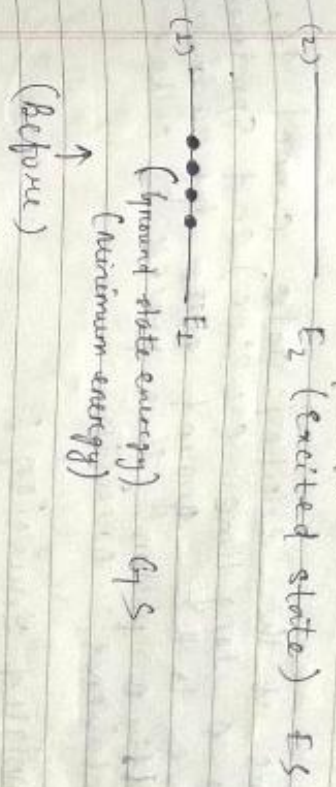
Characteristics of LASER :-

- (i) It is highly intensified beam.
- (ii) It is highly directive beam
- (iii) It is highly coherence beam
- (iv) More monochromatic light beam

Types of emissions

- 1) Stimulated Absorption
- 2) Spontaneous Emission
- 3) Stimulated Emission

Stimulated Absorption :-



Atoms are always available at E_1 (ground state) and they move to higher excited state by absorbing external photon. This process is called stimulated absorption.

Spontaneous emission :-



Atoms at the excited state cannot stay for a long time (i.e. sec) and spontaneously move to the ground state by radiating emitting a photon. This process is called spontaneous emission.

3) Stimulated Emission :-



Atoms move from excited state to E_1 spontaneously by external photon to produce 2 photons. This process is called Stimulated emission.

Terms of LASER :-

1) Pumping :- It is a mechanism by which atoms are shifted / lifted to E_2

EX :- Optical pumping, Electric pumping, Chemical pumping

2) Population Inversion



N_1 - No. of atoms at E_1
 N_2 - No. of atoms at E_2

Generally the no. of atoms at E_1 is more than the no. of atoms at E_2 (i.e. $N_1 > N_2$). By pumping mechanism, the no. of atoms at the excited state is more than the no. of atoms in the ground state. This is called population inversion. Therefore population inversion can be achieved by pumping.

3. Active Center

The atom which is taking part in the lasing process is called 'Active Center'. For Ruby laser $\rightarrow Cr$
 for He-Ne laser $\rightarrow Ne$

4. Active medium

It is the region / medium where the lasing process occurs

5. Lasing Material :- The material which used

for lasing action is known as lasing material.

Ex: solid material \rightarrow Ruby laser
 Gas material \rightarrow He-Ne laser
 Semiconductor material \rightarrow GaAs

6. Resonator cavity:



- The ~~good~~ whole laser apparatus is kept in b/w 2 plate mirrors.
- 1 mirror is having perfectly reflecting surface (M_1)
- Another is having partially reflecting surface (M_2)
- After amplification the laser beam is transmitted through the M_2 as output ray / beam.

Classification in types of LASER:

- Depending on the working process it can be classified as
- 1) Three level laser
 - 2) Four level laser

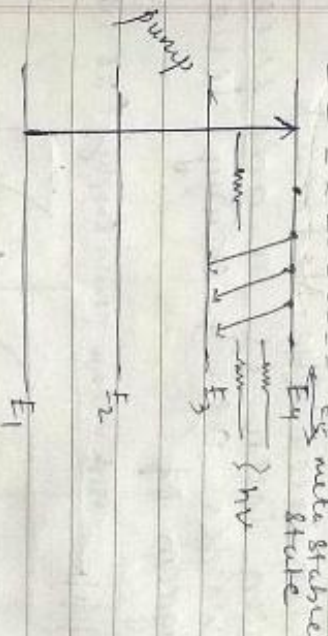
Three-level laser:



Meta stable state:- It is an intermediate state b/w the higher state & its lower state where the atoms are staying for a long time or compare to the excited state.

The lasing action occurs b/w meta stable state and the lower level state. Ex:- Ruby laser

Four-level laser:



In 4-level laser, the lasing action occurs b/w 4 energy levels where E_4 is the meta stable state & the lasing action occurs b/w E_4 & E_3 . Ex:- He-Ne laser

10/10 He-Ne Laser

Ques Discuss the ^{construction} ~~structure~~, ^{working} and applications of He-Ne Laser.

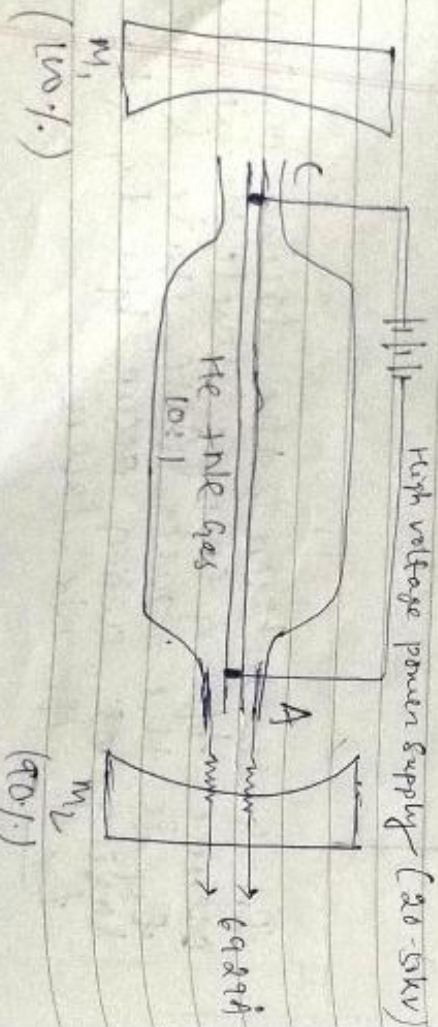
Applications of the LASER :-

- (i) Used in computers and printers
- (ii) Used for entertainment.
- (iii) Used for target location in defense.
- (iv) Used for laser welding.
- (v) Used for medical surgery (eye, dental, plastic surgery).
- (vi) Used for medical applications.
- (vii) Used for scientific applications.
- (viii) Used for making small drills.
- (ix) Used for reading on a sheet & BCR (bar coded reading)

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Helium-Neon laser (He-Ne laser)

- > Helium-Neon laser is a gas laser and it works at 4 energy level.
- > The diagram of He-Ne

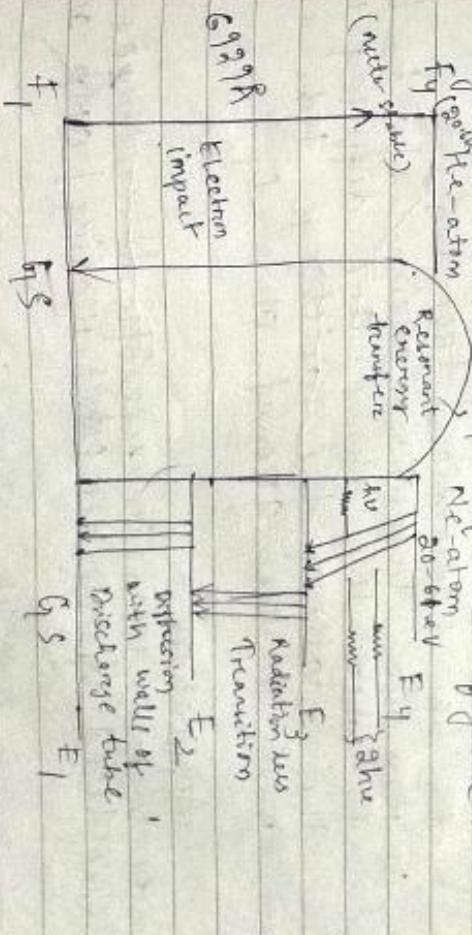


Construction :-

- > It consists of very long and narrow discharge tube with a diameter of 1 cm and a mixture of He-Ne gas with ratio 10:1.
- > Here Neon atom is the active center and Helium atom are providing energy to the Neon atom.
- > It consists of a cathode & anode (very high voltage power supply, 20-50 kV).
- > Here the electric discharge is used for pumping mechanism.
- > The whole apparatus is kept in between the resonator cavity M1 and M2.

Working / Action :-

He-Ne laser works on the principle of 4 energy level and its energy level diagram is shown in the figure.



(i) When the power supply is activated, the a high voltage passes through the gas mixture and electron and ions are produced by electric discharge (pumping).

(ii) The ~~for~~ energetic electron collides with He-Ne atoms and the atoms move to a meta stable state F_4, F_1 respectively.

(iii) The helium atoms transfer the ~~excess~~ energy to the neon atom which is the active center by resonant energy transfer and the helium atom move to the ground state (F_1).

- 1) Neon atoms at the meta stable state F_4 move to the F_3 state by stimulated emission to produce the laser beam.
- 2) Now the transition occurs between F_3 to F_2 i.e. radiometers transition.
- 3) Now the transition occurs b/w F_2 to F_1 where the atoms are diffused with the wall of the discharge tube and move to the ground state F_1 .

Application:-

- (i) Widely used in scientific laboratories.
- (ii) Used for bar coded reading / ORP reading.

Optical fiber :- (Fiber optic) :-
 - Optical fiber are known as glass wires which are made of up glass materials like silica, quartz.
 - The wires/fibers are very thin having diameter (10-50) microns.
 - Optical fibers are used widely for stateless communication, telecommunication.

Parts of Fiber Optic :-
 An optical fiber consists of 3 parts
 1) CORE
 2) CLADDING
 3) COVER (Jacket)



Cone :-
 - The center part of the optical fiber is called the, cone.
 - The cone is made from a glass material having higher refractive index (n_1).
 - The diameter of the core is ~ 50 microns.

Cladding :-

- The core of optical fiber is surrounded by another glass material which is called the cladding.
 - The cladding is made from a glass material having low refractive index (n_2).

The diameter of the cladding is 50-100 microns.

Cover The core & cladding are surrounded by a plastic or polymer material to protect the core. The cladding is known as the cover.

The diameter of cover is 100-200 microns.

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Terms / definition :-

1. Numerical Aperture (NA)



cladding (n_2)

($n_1 > n_2$)

It is defined as the light gathering capacity of the optical fibre. Mathematically, it is given by

$$NA = \sqrt{n_1^2 - n_2^2}$$

n_1 - refractive index of core
 n_2 - refractive index of cladding

2. Acceptance Angle (θ)

It is defined as the maximum angle of incidence of the input light

within which light can pass through the fiber.

Mathematically, it is given as

$$\theta = \sin^{-1} \frac{NA}{n_0}$$

$$\theta = \sin^{-1} \left(\frac{\sqrt{n_1^2 - n_2^2}}{n_0} \right)$$

Total acceptance angle given as 2θ .

Q. The refractive index of core & cladding surfaces are 1.52 & 1.678 find NA & θ

$$NA = \sqrt{n_1^2 - n_2^2} = \sqrt{(1.52)^2 - (1.678)^2}$$

$$= 0.503 \text{ (Ans)}$$

$$\theta = \sin^{-1}(0.503)$$

$$\theta = 30.19^\circ \text{ (Ans)}$$

Q. The NA of a fibre is 0.72 if the refractive of the core is 1.62 then find the θ & refractive of the cladding

$$NA = \sqrt{n_1^2 - n_2^2}$$

$$0.51 = \sqrt{2.11}$$

$$NA^2 = n_1^2 - n_2^2$$

$$n_2 = \sqrt{2.11}$$

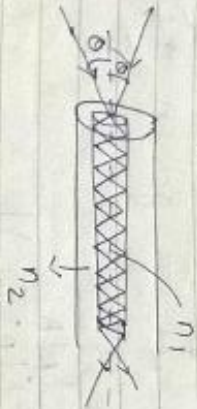
$$-n_2^2 = NA^2 - n_1^2$$

$$n_2 = 1.45$$

$$(0.72)^2 - (1.62)^2$$

$$\theta = \sin^{-1}(0.72) = 46.05^\circ$$

3. Principle of optical fibre :-



Light sources pass through the optical fiber by the successive total internal reflection ($n_1 > n_2$). This is the principle of propagation of optical fiber.

4. Types of fibers :-

(a) according to the propagation of light :-

- 1) Single mode fiber (SMF)
- One light source can pass through the optical fiber.

2) Multi mode fiber (MMF)

In this fiber many no. of light source can pass through the fiber.

(b) According to RI of core/cladding :-

- 1) Step index fiber
- 2) Grad index fiber

Step index fiber (STF)

(i) In STF the refractive index of core & cladding are uniform.

(ii) The magnitude of core, RI to the cladding, RI is sudden. Hence it is known as STF.

(iii) Refractive index profile



(iv) Path of the light

Since $RI_{\text{core}} > RI_{\text{cladding}}$ suddenly from core to cladding, then the light path through the fiber is

Zig-zag path.



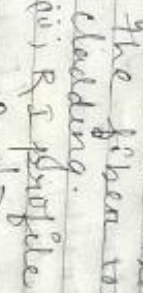
Zig-zag path.

Grad index fiber (GIT)

(i) In GIT, the RI of core is non-uniform whereas the RI of cladding is uniform.

(ii) The magnitude of refractive index of core gradually changes from the axis of the fiber towards the cladding.

(iii) RI profile



(iv) Path of the light



Helical path

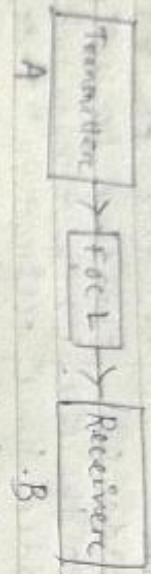
Since, the core RI changes gradually from the cladding, the path of the light through the fiber is

helical path.

Helical path.

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Fiber Optic Communication link / System (FOCL / FOCS)



→ FOCL is widely used for communication system.

→ Generally it is consist of 3 parts

- (a) Transmitter
- (b) Fiber link (FOCL)
- (c) Receiver

The block diagram of FOCL / FOCS is given the following fig:-



- (a) Transmitter: It consist of
- (i) input message
- (ii) Modulator

- (iii) Carrier Source
- (iv) Input channel coupler

Input message :-
The non electrical signal like picture, sound etc are converted to electrical signal.

Modulator :- The information data can be modulated and sent to the carrier source for transmission.

Carrier Source :- Generally laser, LED or high frequency light source are used as carrier source for data transmission.

Input channel coupler :-
The modulated data through the carrier source are sent to the fiber link by input channel coupler.

(b) FOCL :-
The data or information prepared by transmitter can be transmitted properly through FOCL.

- (c) Receiver: It consists of
- (i) Output channel coupler
- (ii) Detector
- (iii) Signal processor
- (iv) Output message.

Output channel coupler :-
The information received through FOC

Detector :-
The information on data is detected which was received from output channel coupler.

Signal processor :- In this unit the signal is processed for final transmission.

Output message :- The electrical signal is converted to non-electrical signal.

Advantages :-

- It has ~~more~~ immunity to electromagnetic interference.
- It has high data security.
- It is a non-conducting cable.
- It has low weight & cost.
- It has ^{convenient} bend width & high ~~transmission~~ distance.

Disadvantages :-

- the cost for under laying is more as compared to overhead connection.
- breaking of fibers.
- Replacing the fibers rather than repairing is costly.

Uses :-

- ~~inter~~ widely used in telecommunication and data link communication system.
- It is used as different types of sensors like temperature, pressure, distance.
- Used in medical science.
- ex - endoscope.
- Used for super computers, rocket, satellites etc.

Fiber loss :-

During transmission of signal through the optical fiber, different factors (attenuating) are affecting the loss of signal (fiber loss).

Some factors are :-

- (i) Loss due to dispersion.
- (ii) Loss due to bending.
- (iii) Loss due to material.
- (iv) Loss due to scattering.